

Dielectric constant at metal/water interfaces

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Introduction

The dielectric constant at the interface directly influences the interfacial capacitance and the interfacial electric field. Therewith, it also influences reaction energetics and reaction kinetics. Knowledge of the interfacial dielectric constant is therefore relevant. Unfortunately, relatively little is known about how the dielectric constant changes as we approach the interface. Here, we study the behaviour of two contributions to the dielectric constant, the electronic dielectric constant and the orientational one, by using machine-learnt potential and ab initio calculations.

Electronic dielectric constant

Computational setup:





Project overview



Aiming at sufficient sampling with *ab initio* accuracy, we trained a machine-learnt potential (MLP). Based on the trajectories from MLP sampling, we can calculate 1) the orientational dielectric constant from the **dipole fluctuations** and 2) the electronic dielectric constant from the **polarization charges**.

PW CUTOFF: 400 Ry Functional: PBE+D3 **Dirichlet BC in Z and PBC in XY**

Calculate polarization charges from the electron density changes under various fields^[3]

Calculate the electronic dielectric constant from the polari zation charge



Model system: *Pt(100)/H*₂*O interface*

Orientational dielectric constant ^{[1][2]}

$$\varepsilon_{\perp}^{-1}(z) = 1 - \frac{\left\langle m_{\perp,0}(z)M_{\perp,0} \right\rangle - \left\langle m_{\perp,0}(z) \right\rangle \left\langle M_{\perp,0} \right\rangle}{\varepsilon_{0}k_{B}T + \left(\left\langle M_{\perp,0}^{2} \right\rangle - \left\langle M_{\perp,0} \right\rangle^{2}\right)/V}$$

m(z): local polarization; **M**: total dipole moment *SPC/E water: -0.8476 for O, 0.4238 for H





BUT! Level alignment issue?!







ET from water to metal

References [1] Stern, H. A.; Feller, S. E. J. Chem. Phys. 2003, 118, 3401. [2] Bonthuis, D. J.; Gekle, S.; Netz, R. R. Phys. Rev. Lett. 2011, 107, 1. [3] Giustino, F.; Pasquarello, A. Phys. Rev. B 2005, 71, 144104.

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